

Docket No.: 263261US0PCT

McClelland Maier

NEUSTADT

OBLON SPIVAK

P.C.

ATTORNEYS AT LAW

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

RE: Application Serial No.: 10/518,025

Applicants: Hitoshi KATO, et al. Filing Date: December 15, 2004

For: CVD METHOD FOR FORMING SILICON NITRIDE

FILM ON TARGET SUBSTRATE

Group Art Unit: 2813

Examiner: HARRISON, MONICA D.

SIR:

Attached hereto for filing are the following papers:

Letter

Written Opinion of the International Searching Authority with English Translation

Our check in the amount of \$0.00 is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,

MAIER & NEUSTADT, P.C.

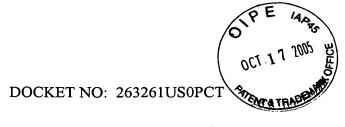
Norman F. Oblon

Frederick D. Vastine

Registration No. 27,013

Customer Number

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#### IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

HITOSHI KATO ET AL

: EXAMINER: HARRISON, M.

SERIAL NO: 10/518,025

FILED: DECEMBER 15, 2004

: GROUP ART UNIT: 2813

FOR: METHOD OF CVD FOR FORMING SILICON NITRIDE FILM ON SUBSTATE

#### LETTER

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

Applicants wish to make of record the attached English translation of the Written Opinion of the International Searching Authority. Copies of the references listed therein were filed on December 15, 2004.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C. Norman F. Oblon

**Customer Number** 22850

Tel: (703) 413-3000 Fax: (703) 413 -2220 (OSMMN 06/04)

Frederick D. Vastine Registration No. 27,013

### PATENT COOPERATION TREATY

From the INTERNATIONAL SEARCHING AUTHORIT	Υ		30	
To:			PCT PCT	
			RITTEN OPINION OF THE IONAL SEARCHING AUTHORITY	
			(PCT Rule 43bis.1)	
		Date of mailing (day/month/year)	20-04-2004	
Applicant's or agent's file reference	•	FOR FURTHER	i i	
03S1860P			See paragraph 2 below	
International application No.	nternational filing date	(dav/month/vear)	Priority date (day/month/year)	
PCT/JP2004/000370	19-01-2004		24-01-2003	
<u> </u>				
International Patent Classification (IPC) or both n	national classification an	d IPC		
H01L 21/318, C23C 16/3	34			
Applicant				
TOKYO ELECTRON LIMITE	D			
This opinion contains indications relating	ng to the following item	e.		
		<b>.</b>		
Box No. I Basis of the o	pinion			
Box No. II Priority				
Box No. III Non-establish	ment of opinion with re	gard to novelty, inven	tive step and industrial applicability	
Box No. IV Lack of unity	of invention			
Box No. V Reasoned state applicability;	tement under Rule 43 <i>bis</i> citations and explanatio	.1(a)(i) with regard to ns supporting such sta	novelty, inventive step or industrial stement	
Box No. VI Certain docum	nents cited			
Box No. VII Certain defect	ts in the international ap	plication		
Box No. VIII Certain observ	vations on the internation	nal application	·	
2. FURTHER ACTION				
International Preliminary Examining A	uthority ("IPEA") exceptions and the control of the	pt that this does not a d the International Bu	rill be considered to be a written opinion of the pply where the applicant chooses an Authority other treau under Rule 66.1 bis(b) that written opinions of	
If this opinion is, as provided above, considered to be a written opinion of the IPEA, the applicant is invited to submit to the IPE written reply together, where appropriate, with amendments, before the expiration of 3 months from the date of mailing of F PCT/ISA/220 or before the expiration of 22 months from the priority date, whichever expires later.				
For further options, see Form PCT/ISA		, , , , , , , , , , , , , , , , , , , ,	•	
3. For further details, see notes to Form PCT/ISA/220.				
Name and mailing address of the ISA/JP	Date of completion	of this opinion Au	thorized officer	
		1		
Facsimile No.		Tel	ephone No.	

Form PCT/ISA/237 (cover sheet) (April 2005)

# WRITTEN OPINION OF THE INTERNATIONAL SEARCHING AUTHORITY

International application No.
PCT/JP2004/000370

Box	No. I	Basis of the report	
1.	With	regard to the language, this opinion has been established on the basis of:	
		the international application in the language in which it was filed	
		the translation of the international application into	, which is the language of a
		translation furnished for the purposes of international search (Rule 12.3(a) and 23.1(b)).	
2.	With	regard to any nucleotide and/or amino acid sequence disclosed in the international application tion, this opinion has been established on the basis of:	and necessary to the claimed
	a.	type of material	
		a sequence listing	
		table(s) related to the sequence listing	·
	ъ.	format of material	
		on paper	:
		in electronic form	
	c.	time of filing/furnishing	
		contained in the international application as filed	
		filed together with the international application in electronic form	
		furnished subsequently to this Authority for the purposes of search	
		<b>_</b>	
3.		In addition, in the case that more than one version or copy of a sequence listing and/or table(s) rel furnished, the required statements that the information in the subsequent or additional copies is identi- filed or does not go beyond the application as filed, as appropriate, were furnished.	ating thereto has been filed or ical to that in the application as
	٠		
4.	Add	tional comments:	
	•		
			·
			·
			·

International application No.

		AL SEARCHING		PCT/JP2004/000370	o
Box				nventive step or industrial applicability;	
1.	citations and expla	inations supportin	ig such statement		
•			1	-15	VEO
	Novelty (N)			-15	_ YES   NO
		Claims			_ 110
	Inventive step (IS)	Claims		-15	YES
		Claims			_ NO
	Industrial applicability (IA)	Claims	1	-15	YES
					NO
	<del></del>				
2.	Citations and explanations:			•	
	D		272106 A (Sony	Corp.), 20 October	
·	Document 1		.273106 A (50Hy	corp.,, zo occober	
		1995			
			•		
	Claims 1 t			·	
	The	inventio	n set forth in o	claims 1 to 15	
	involves a	an invent	ive step relativ	ve to document 1	
	cited in t	he inter	national search	report. Document 1	
	does not d	disclose	a feature where:	in a treatment gas	
	contains h	nexaethyl	aminodisilane	gas.	
		-			

## WRITTEN OPINION OF THE INTERNATIONAL SEARCHING AUTHORITY

International application No.
PCT/JP2004/000370

x No. VI	Certain documents ci					
Certain p	ublished documents (Rule 4	3 <i>bis</i> .1 and 70.1	<b>0)</b> ·			
	Application No. Patent No.		Publication date (day/month/year)	Filing date (day/month/year)	Priority (da	date (valid claim y/month/year)
	WO 03/046253	A1	05-06-03	27-11-02	3 (	0-11-01
	[E, X]					
				•		
						·
						·
Non-writ	tten disclosures (Rule 43 <i>bis</i> .	1 and 70.9)			· ·	
Non-writ	tten disclosures (Rule 43 <i>bis</i> .  Kind of non-written disc		Date of non-written o (day/month/ye		Date of writter ferring to non-w (day/mont	ritten disclosure
Non-writ					ferring to non-w	ritten disclosure
Non-writ					ferring to non-w	ritten disclosure
Non-writ					ferring to non-w	ritten disclosure
Non-writ					ferring to non-w	ritten disclosure
Non-writ				<i>ar)</i> ref	ferring to non-w (day/mont	ritten disclosure h/year)
Non-writ					ferring to non-w (day/mont	ritten disclosure h/year)
Non-writ				<i>ar)</i> ref	ferring to non-w (day/mont	ritten disclosure h/year)
		losure	(day/month/ye	ar) ref	ferring to non-w	ritten disclosure h/year)
	Kind of non-written disc	losure	(day/month/ye	ar) ref	ferring to non-w	ritten disclosure h/year)
	Kind of non-written disc	losure	(day/month/ye	ar) ref	ferring to non-w	ritten disclosure h/year)

#### 発信人 日本国特許庁(国際調査機関)

出願人代理人			•		
鈴江 武彦					
	様				
あて名					
T 100-0013			PCT 国際調査機関の見解書		
1 100-0013			(法施行規則第40条の2)		
東京都千代田区霞が関3丁目7番2	号鈴榮特許綜合		[PCT規則43の2.1]		
<b>法律事務所内</b>		発送日	1		
		(日.月.年)	20, 4, 200	4	
ILLES 1 TO DA (NATE I		A (( a T (a + ) =			
出願人又は代理人 の書類記号 03S18	860P	一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一一	ついては、下記2を参照っ	<b>「ること。</b>	
国際出願番号	国際出願日		優先日		
PCT/JP2004/000370 (	日.月.年) 19. (	01.2004	(日.月.年) 24. (	01. 2003	
国際特許分類 (IPC)					
ELECTION OF CALL OF	Int. Cl' H01L 21/3	18, C23C 16/34			
出願人(氏名又は名称)					
	東京エレクトロ	ン株式会社			
1. この見解書は次の内容を含む。					
さらなる選択肢は、様式PCT/ISA/220を参照すること。					
3. さらなる詳細は、様式PCT/ISA/220の備考を参照すること。					
見解書を作成した日 07.04.2004					
名称及びあて先 日本国特許庁 (ISA/JP) 郵便番号100-8915	#	寺許庁審査官(権 和	限のある職員) 瀬田 芳正	4R 2929	

様式PCT/ISA/237 (表紙) (2004年1月)

東京都千代田区霞が関三丁目4番3号

電話番号 03-3581-1101 内線

1. この見解書は、  	下記に示す場合を除くほか、国際出願の言語を基礎として作成された。	
	t、 語による翻訳文を基礎として作成した。 場査のために提出されたPCT規則12.3及び23.1(b)にいう翻訳文の言語である。	
2. この国際出願で別以下に基づき見角	<b>開示されかつ請求の範囲に係る発明に不可欠なヌクレオチド又はアミノ酸配列に関して、</b> 解事を作成した。	
a. タイプ	配列表	
·	配列表に関連するテーブル	
b. フォーマット	<b>一</b>	
	コンピュータ読み取り可能な形式	
c . 提出時期	出願時の国際出願に含まれる	
	この国際出願と共にコンピュータ読み取り可能な形式により提出された	
	出願後に、調査のために、この国際調査機関に提出された	
1 1	列表又は配列表に関連するテーブルを提出した場合に、出願後に提出した配列若しくは追加して提出 頭時に提出した配列と同一である旨、又は、出願時の開示を超える事項を含まない旨の陳述書の提出。 	
, 4. 補足意見:		
-		
-		
-		

#### 国際調査機関の見解書

国際出願番号 PCT/JP2004/000370

· 見解			
	,		•
新規性(N)	請求の範囲	1-15	有
	請求の範囲		無
進歩性(IS)	請求の範囲	1 15	<del>-</del>
世 <b>少</b> 性(13)	請求の範囲	1-15	
	•		
産業上の利用可能性(IA)	請求の範囲	1-15	
•	請求の範囲		無

#### 2. 文献及び説明

文献 1: JP 7-273106 A (ソニー株式会社), 1995.10.20

### 請求の範囲1-15

請求の範囲1-15に記載された発明は、国際調査報告に引用された文献1に対して進歩性を有する。文献1には処理ガスがヘキサエチルアミノジシランガスを含むことが記載されていない。

#### 国際調査機関の見解書

国際出願番号 PCT/JP2004/000370

第VI欄	ある種の引用文献

1. ある種の公表された文書(PCT規則43の2.1及び70.10)

出願番号 特許番号	公知日	出願日	優先日(有効な優先権の主張)
	(日.月.年)	_(日.月.年)	(日.月.年)
WO 03/046253 A1 FE, XJ	05. 06. 03	27. 11. 02	30. 11. 01

2. 書面による開示以外の開示(PCT規則43の2.1及び70.9)

書面による開示以外の開示の種類書面による開示以外の開示の目付書面による開示以外の開示に言及している(日、月、年)書面の日付(日、月、年)